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U.S. UTILITY Patent Application

PATENT NUMBER and
ISSUE DATE

APPL NUM 10084828	FILING DATE 02/28/2002	CLASS 430	SUBCLASS 270.1	GAU 1752	EXAMINER CLARKE
**APPLICANTS: Harada Yuji; Watanabe Jun; Hatakeyama Jun; Kawai Yoshio; Sasago Masaru; Endo Masayuki; Kishimura Shinji; Ootani Michitaka; Miyazawa Satoru; Tsutsumi Kentaro; Maeda Kazuhiko;					
**CONTINUING DATA VERIFIED:					
** FOREIGN APPLICATIONS VERIFIED: JAPAN 2001-053664 02/28/2001 JAPAN 2001-053669 02/28/2001					
PG-PUB <input type="checkbox"/>		DO NOT PUBLISH <input type="checkbox"/>		RESCIND <input type="checkbox"/>	
Foreign priority claimed <input type="checkbox"/> yes <input type="checkbox"/> no		35 USC 119 conditions met <input type="checkbox"/> yes <input type="checkbox"/> no		ATTORNEY DOCKET NO KOJIM-449	
Verified and Acknowledged Examiners's initials					
TITLE : Polymers, resist compositions and patterning process					

U.S. DEPT. OF COMM. / PAT. & TM-PTO-436L (Rev. 12-94)

NOTICE OF ALLOWANCE MAILED		Assistant Examiner	CLAIMS ALLOWED	
			Total Claims	Print Claim for O.G.
ISSUE FEE		Primary Examiner	DRAWING	
Amount Due	Date Paid		Sheets Drwg.	Figs. Drwg.
<input type="checkbox"/> TERMINAL DISCLAIMER		PREPARED FOR ISSUE	Application Examiner	
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